Chemical Solution Deposition of Functional Oxide Thin Films

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ISBN 978 3 211 99310 1
Format (B x L): 15,5 x 23,5 cm
Gewicht: 1382 g

Weitere Fachgebiete > Technik > Verfahrenstechnik, Chemieingenieurwesen, Lebensmitteltechnik > Technologie der Oberflächenbeschichtung
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Chemical Solution Deposition of Functional Oxide Thin Films  
2013, XVII, 796 p. 390 illus., 133 illus. in color., Hardcover  
ISBN: 978-3-211-99310-1